Docket No.: 1982-0208P

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the present application.

1. (Currently Amended) A photothermographic material comprising a support and an image-forming layer disposed on the support, wherein the image-forming layer comprises a photosensitive silver halide, a non-photosensitive organic silver salt, a reducing agent and a binder, and the binder comprises a polymer formed by copolymerization of monomers including 10 to 70% by mass of a monomer represented by the following formula (M):

Formula (M)

$$CH_2 = CR^{01} - CR^{02} = CH_2$$

wherein R^{01} represents a hydrogen atom, an alkyl group having 1 to 6 carbon atoms, a halogen atom, or a cyano group; and R^{02} represents an alkyl group having 1 to 6 carbon atoms, a halogen atom, or a cyano group; wherein R^{01} and R^{02} are never both simultaneously a hydrogen atom; and

the polymer is dispersed in the binder as latex in the image-forming layer.

2. (Original) A photothermographic material according to claim 1, wherein the imageforming layer contains an antifoggant formed from an organic polyhalogen compound.

Docket No.: 1982-0208P

3. (Original) A photothermographic material according to claim 2, wherein the organic polyhalogen compound is represented by the following formula (H):

Formula (H)

$$Q-(Y)n-C(Z_1)(Z_2)X$$

wherein Q represents an alkyl group, an aryl group, or a heterocyclic group; Y represents a divalent linking group; n represents an integer of 0 or 1; Z_1 and Z_2 represent a halogen atom, respectively; and X represents a hydrogen atom or an electron-withdrawing group.

- 4. (Original) A photothermographic material according to claim 2, wherein the amount of the antifoggant is 0.01 to 0.5 g/m².
- 5. (Original) A photothermographic material according to claim 3, wherein the amount of the antifoggant is 0.01 to 0.5 g/m².
- 6. (Original) A photothermographic material according to claim 1, wherein the polymer has a glass-transition temperature of -30 to 70°C.
- 7. (Original) A photothermographic material according to claim 2, wherein the polymer has a glass-transition temperature of -30 to 70°C.

Application No. 10/724,706 Art Unit 1752 Preliminary Amendment With RCE

8. (Original) A photothermographic material according to claim 3, wherein the polymer has a glass-transition temperature of -30 to 70°C.

Docket No.: 1982-0208P

- 9. (Original) A photothermographic material according to claim 4, wherein the polymer has a glass-transition temperature of -30 to 70°C.
- 10. (**Original**) A photothermographic material according to claim 1, wherein the polymer is a polymer latex synthesized by an emulsion polymerization.
- 11. (**Original**) A photothermographic material according to claim 2, wherein the polymer is a polymer latex synthesized by an emulsion polymerization.
- 12. (**Original**) A photothermographic material according to claim 3, wherein the polymer is a polymer latex synthesized by an emulsion polymerization.
- 13. (Original) A photothermographic material according to claim 1, wherein R^{01} is a hydrogen atom and R^{02} is a methyl group in the formula (M).
- 14. (Original) A photothermographic material according to claim 2, wherein R^{01} is a hydrogen atom and R^{02} is a methyl group in the formula (M).

4 of 7 MSW/ETP/las

Application No. 10/724,706 Art Unit 1752 Preliminary Amendment With RCE Docket No.: 1982-0208P

- 15. (Original) A photothermographic material according to claim 3, wherein R^{01} is a hydrogen atom and R^{02} is a methyl group in the formula (M).
- 16. (Original) A photothermographic material according to claim 1, wherein the polymer is copolymerized with monomers at 1 to 20% by mass, said monomers having acid groups.
- 17. (**Original**) A photothermographic material according to claim 2, wherein the polymer is copolymerized with monomers at 1 to 20% by mass, said monomers having acid groups.
- 18. (Original) A photothermographic material according to claim 3, wherein the polymer is copolymerized with monomers at 1 to 20% by mass, said monomers having acid groups.